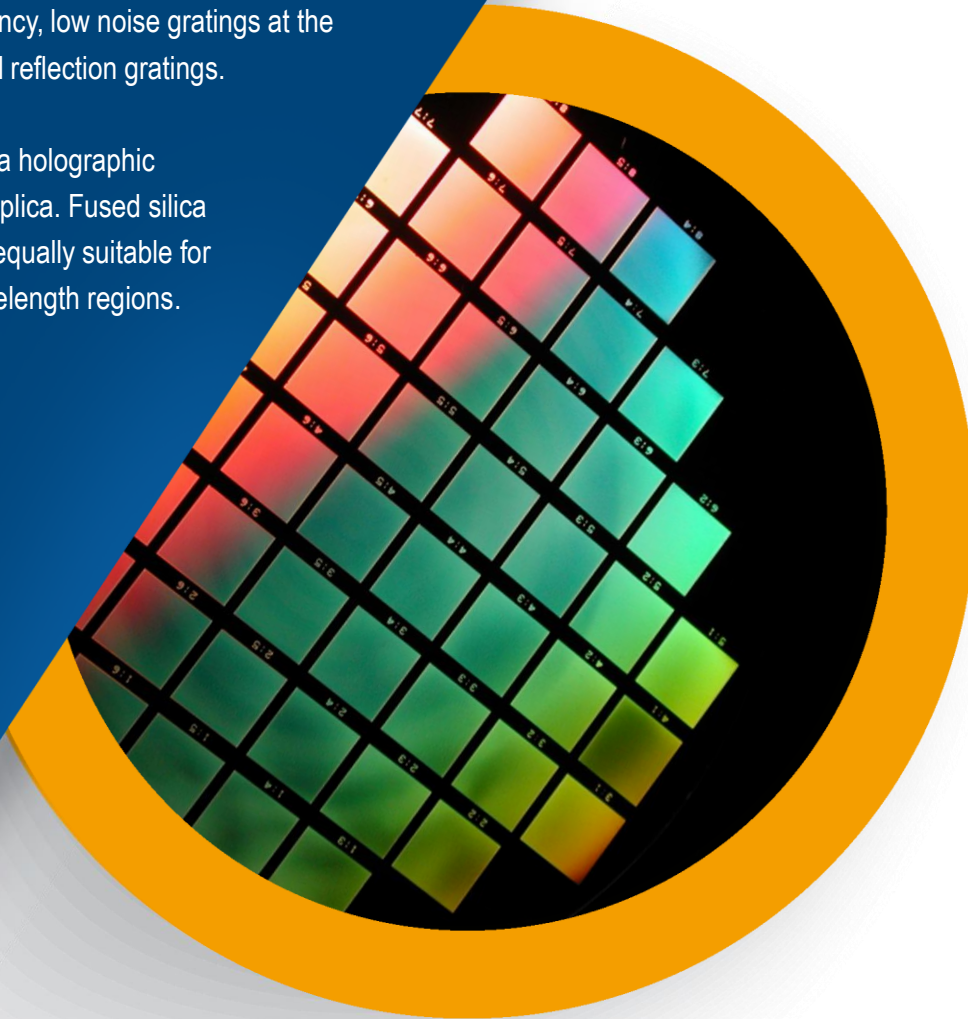


Fused silica transmission grating technology enables high resolution, high efficiency gratings that are ideal for compact spectrometers



Transmission gratings from Ibsen build on leadership in fused silica transmission grating technology. The superior performance of holography, combined with wafer-based Holostepper™ processing, makes possible high resolution, high efficiency, low noise gratings at the cost level of traditional reflection gratings.

Each Ibsen grating is a holographic masterpiece - not a replica. Fused silica grating technology is equally suitable for UV, VIS and NIR wavelength regions.



Spectrometer Grating

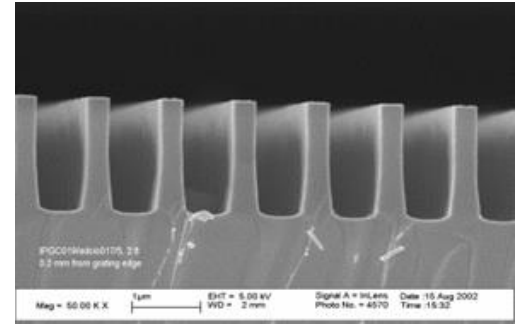
1274 l/mm for 360 – 830

FSTG-XVIS1274-904

1274 l/mm for 360 – 830

FSTG-XVIS1274-904

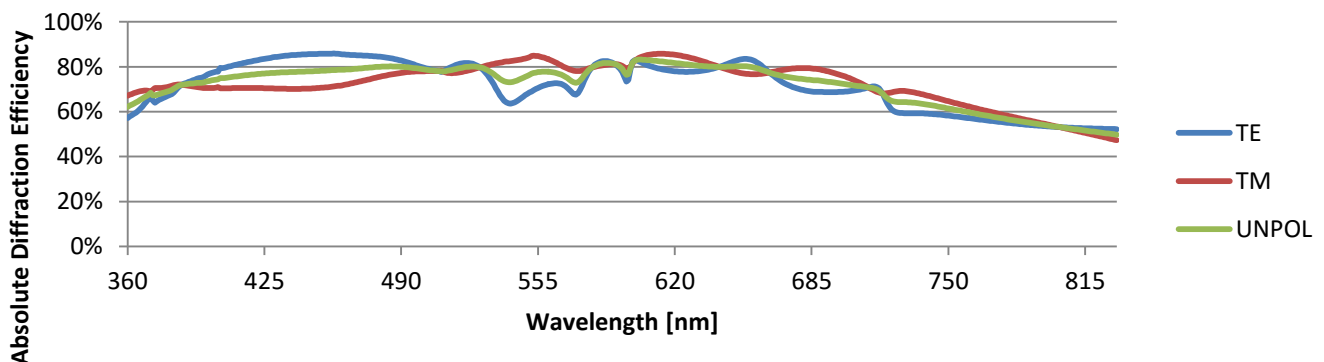
| Benefits |
|--|
| High diffraction efficiency combined with high dispersion |
| Low polarization dependence over broad spectral range |
| Unbeatable temperature and environmental tolerance |
| Transmission configuration offers flexible and tolerant design |
| Low stray light and low wavefront distortion |



| Parameter | Specification |
|--|--|
| Materials | Fused silica and high-power, dielectric AR coating materials |
| Grating area | 4 mm x 4 mm |
| Chip size | 5 mm x 7 mm |
| Chip thickness | 0.625 mm |
| Grating resolution | 1274 l/mm |
| Dispersion at 532 nm | 0.079 deg/nm |
| Angle of incidence (AOI) | 17.3 deg |
| Illumination bandwidth | 360 – 830 nm |
| Diffraction efficiency, unpolarized | >40%, all wavelengths |
| Coefficient of thermal expansion (CTE) | 0.5 ppm/K |
| Maximum operating temperature | >500 degrees C |
| Cleaning recommendation | First contact. Available from Photonic Cleaning |

Typical grating performance

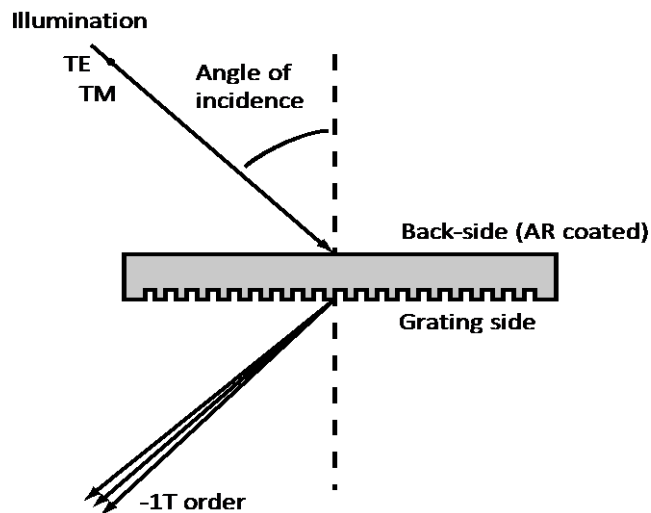
1274 l/mm for 360-830 nm



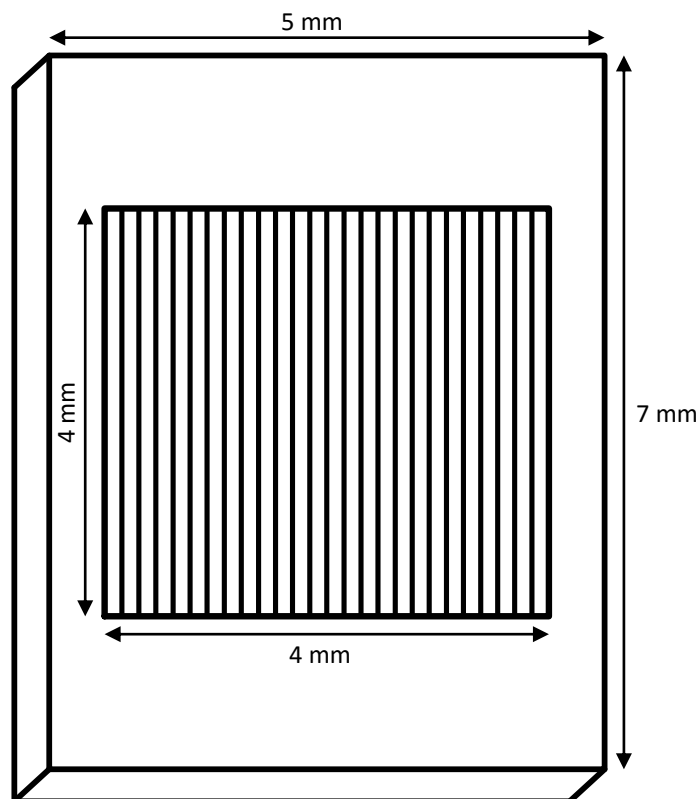
1274 l/mm for 360 – 830

FSTG-XVIS1274-904

Configuration/definitions



Drawing



Specifications are subject to change without notice.

The above grating is an example of Ibsen's capabilities. Ibsen operates as grating partner for our customers, from being an integrated part of the grating and device / instrument design phase, to the manufacturing of prototypes, to volume manufacturing of OEM gratings.